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Homework 5 – due December 7, 2018 by 5:00pm

1. A Si *n-p-n* BJT has emitter, base and collector doping levels of 10^{19} cm^{-3} , $5 \times 10^{18} \text{ cm}^{-3}$, and 10^{17} cm^{-3} , respectively. It is biased in the normal active mode, with a base-emitter voltage $V_{BE} = 1\text{V}$ and a collector-emitter voltage $V_{CE} = 4\text{V}$. During operation, the current through the device causes it to heat up to 400 K, such that $n_i = 10^{12} \text{ cm}^{-3}$, and $\epsilon_r = 15$. Assume electron and hole mobilities of 500 and 100 $\text{cm}^2/\text{V}\cdot\text{s}$, respectively, in the emitter, and 800 and 250 $\text{cm}^2/\text{V}\cdot\text{s}$, respectively, in the base. Assume the minority carrier lifetimes are 1 ns everywhere. If the neutral base width is 500 nm and the neutral emitter is 3 μm wide, calculate the emitter current density J_E , the emitter injection efficiency γ , and the base transport factor α_T . Qualitatively sketch the device structure showing the minority carrier concentrations in the emitter and the base, and sketch the band diagram under bias below it.
2. Problem 7.20 in Streetman.
3. For the BJT in the previous problem, calculate γ , α_T , β , I_E , I_B , and I_C for the two values of V_{EB} .
4. Reading Assignment: *Streetman*: Ch. 7 (sections 7.1-7.2 and 7.4-7.6)